

# Accepted Manuscript

Photolithographically patterned N-channel organic thin film transistors using sensitized polyvinyl alcohol

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PII: S1566-1199(18)30048-X

DOI: [10.1016/j.orgel.2018.02.006](https://doi.org/10.1016/j.orgel.2018.02.006)

Reference: ORGELE 4520

To appear in: *Organic Electronics*

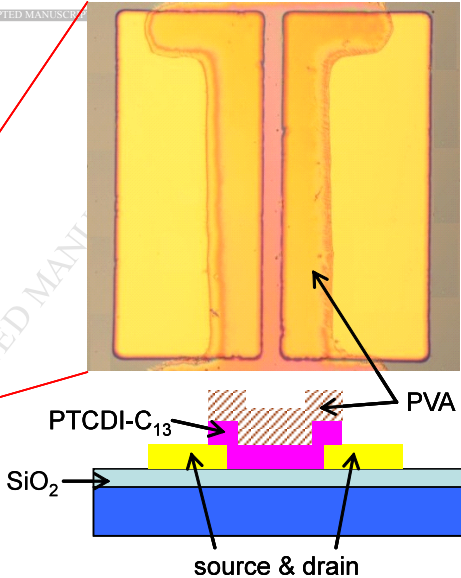
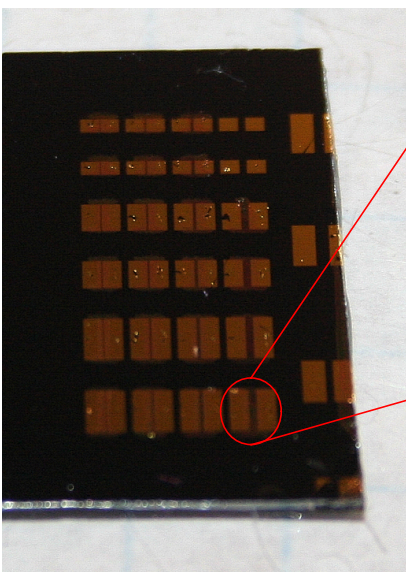
Received Date: 24 October 2017

Revised Date: 22 January 2018

Accepted Date: 5 February 2018

Please cite this article as: A.G. Ismail, Photolithographically patterned N-channel organic thin film transistors using sensitized polyvinyl alcohol, *Organic Electronics* (2018), doi: 10.1016/j.orgel.2018.02.006.

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